

IN THE SPECIFICATION:

Please amend the specification as follows:

Paragraph beginning on page 1, at prenumbered line 5, has been amended as follows:

[0001] The present invention is an electropolishing process ~~means~~ device for inner and outer surfaces of a metal, ~~especially applied to a metal that inner and outer surfaces both needing high clean and passivation~~ more specifically for cleaning and passivation of the inner and outer surfaces of the metal.

Paragraph beginning on page 1, at prenumbered line 9, has been amended as follows:

[0002] A process of electropolishing is to connect a workpiece to an anode and a metal to a cathode, aforesaid whole structure of workpiece connecting to anode and electrode connecting to cathode is put into electrolyte for electrifying direct current, thus defects on workpiece surface are removed ~~and the surface is then to produce a surface that is~~ shining and smooth. Features Benefits of electrolysis and polish ~~that~~ improving surface cleanness, roughness, passivation, etc. ~~For different fields of Industry, such as semiconductor, chemical industry, biochemical engineering, food industry, needed tubes of aforesaid fields are to deliver fluids of those fields~~ need tubes to deliver fluids, and inner surfaces of tubes are treated by polish or electrolysis to approach high cleanness and anti-corrosion. Especially, products of IC/LCD/III-V require high standards of cleanness and anti-corrosion, thus, applying the present invention to said products is a challenge.

Paragraph beginning on page 1, at prenumbered line 22, has been amended as follows:

[0003] In prior arts of US Patent No. 4826582 and 4849084, which ~~were figuring out part of the technologies for~~ taught a part of the technologies for electropolishing a 10-meter heat exchange tube, ~~and~~ utilized an electrode device for positioning a workpiece and required sealing an electrolyte ~~is a must~~. The prior arts

adopt a 3-layer structure of delivering electrolyte of high pressure air, but unfortunately said structure is very complicate and only suitable for the larger diameter workpieces, not for the tube of inside diameter under 3 cm.

Paragraph beginning on page 1, at prenumbered line 29, has been amended as follows:

[0004] In the prior art of US Patent Number 5958195, ~~which was taught~~ the technology of electropolishing an inner surface of a long and ~~bended~~ bent tube. However, to electropolish a ~~bended~~ bent tube, an electrode must move ~~alone~~ bended curve for not happening along a curve and prevent short circuit. The most important parts are a flexible electrode and an insulation device. The insulation device is to avoid short circuit and non-concentricity, but this kind of devices block electrolyte flowing and make an un-average electric field. etc.

Paragraph beginning on page 2, at prenumbered line 6, has been amended as follows:

[0005] In The prior arts of US Patent Number 4601802 and 4,705611, ~~which offer a fixed applied an inside~~ disclose a fixture applied inside a tube, and the fixture stabilizes a plurality of axially rotating tubes simultaneously. An end connector can circulate tube and exhaust gas from an upper end, and electrolyte can be recycled after overflowing. An electrode length is equal to the tube length, therefore a huge space and a super power supplier are needed ~~to fit for~~ for such conditions.

Paragraph beginning on page 2, at prenumbered line 12, has been amended as follows:

[0006] Based on the aforesaid issues, the present inventor of the ~~patent has being~~ invention has studied and referred to practical experiences and theory for ~~designing to design~~ and effectively improve ~~improving~~ the prior arts.

Paragraph beginning on page 2, at prenumbered line 22, has been amended as follows:

[0008] The second object is to offer an electropolishing process means for inner and outer surfaces of a metal, which can treat both inside and outside of a workpiece simultaneously, and the workpiece inner diameter is smaller than one inch; ~~a structure of the means is simple to save an~~ . The device has a simple structure that will save on equipment cost.

Paragraph beginning on page 3, at prenumbered line 16, has been amended as follows:

[0016] For different fields of semiconductor, pharmaceutical industry, chemical industry, biochemical engineering, food industry, inner surfaces of needed tubes and fitting of aforesaid fields are treated by electropolishing process for improving surface cleanness, roughness and passivation results. The present invention comprises an electrolyte delivering system, which ~~makes electrolyte averagely pass through~~ passes electrolyte across both inner and outer surfaces of a metal and the electrolyte is an electrifying media to make a complete electric circuit path; ~~electrolyte~~. Electrolyte is delivered by the electrolyte delivering system for recycling.

Paragraph beginning on page 3, at prenumbered line 25, has been amended as follows:

[0017] Referring to figure 1, which is a scheme of an electropolishing process equipment of the present invention. A revolving stage 200 has a plurality of tanks, which ~~including~~ includes two electrolyte polishing tanks 202, 203, two water rinse tanks 204, 206, one nitric acid rinse tank 205, one hot deionization water rinse tank 207 and one drying tank 208. A workpiece (not shown in figure) for polishing is hung up from a loading and unloading area 201, the revolving stage 200 timely controls to rotate the workpiece to each tank. The electrolytic polishing tanks 202, 203 which electrolyte contents are sulfuric acid of 10-50%, phosphoric acid of 50-90%, glycerol of 1-10%, and its temperature is 25-100 °C; nitric acid rinse tank 205 which nitric acid content is 10-40%, and its temperature is 25-90 °C. The present invention connects to the revolving stage 200 via an over-hanging beam

209, and the over-hanging beam 209 is a cam mechanism 210 to shake for reducing air bulbs when reaction is being preceded.

Paragraph beginning on page 4, at prenumbered line 8, has been amended as follows:

[0018] Referring to figure 2, which is a scheme of an electrolytic polishing tank and related equipment of the present invention. An electropolishing process means 300 of the present invention is placed in an electropolishing tank 202 for electrochemical reaction. Wherein, the electrolytic polishing tank 202 is the first huge polishing procedure; electrolyte is delivered by an anti-corrosion pump 24 to electrolytic polishing tank 202 from tank bottom, and it is then heated by a heater 21 and flows from lower to upper place of the tank 202 through a meshed plate 20; when electrolyte is up to a certain height, it overflows a partition 22 to a temporary electrolyte storing tank 23 when electrolyte amount is more than tank capacity, and then the pump 24 cooperate with a pipe 25 to recycle electrolyte. The heater 21 is to heat and also has thermal insulation function; the meshed plate 20 is to uniformly distribute electrolyte flow from bottom to upper plate of tank 202. An electropolishing tank 203 is the second procedure, and the difference between the two electrolytic polishing tanks 202 and 203 is that those two current intensities are different, and the two current intensities are designed to fit the other procedures as well. ~~For other tanks, which are not involved in the present invention, so they are not discussed any further here.~~

Paragraph beginning on page 4, at prenumbered line 27, has been amended as follows:

[0019] Please refer to figures 3 and 4, which are a sectional view of a preferred embodiment of the present invention and an enlarged view of the preferred embodiment of figure 3. The embodiment comprises an electrode device, which ~~included~~ includes a positive electrode guide 135, a negative electrode guide 145, a positive electrode plate 140, a negative electrode plate 130 and a negative working electrode 160, the positive electrode guide 135 connects to the positive electrode plate 140 and a workpiece 100 for offering a function of positive electrode,

the negative electrode guide 145 connects to the negative working electrode 160 via the negative electrode plate 130 for offering a function of negative electrode, ~~an~~ a connection part of negative electrode plate 130 and negative working electrode 160 has a working electrode hole 190 and a negative electrode fixture 170 for placing and positioning negative working electrode 160, such layout is to offer a negative power source when electrifying; a clamping apparatus, which ~~including~~ includes at least one insulated screw 180, one upper insulated piece 172 and one lower insulated piece 173, the insulated screw 180 gets positive electrode plate 140 and negative electrode plate 130 together with an upper insulated cover 110 and ~~an~~ a lower insulated plate 120 in between, wherein, negative electrode plate 130 is on a bottom of the lower insulated plate 120, positive electrode plate 140 is between the upper insulated cover 110 and lower insulated plate 120, the upper insulated piece 172 and the lower insulated piece 173 are individually set in two middles of the insulated screw 180 with positive electrode plate 140 and insulated screw 180 with negative electrode plate 130 for preventing electric leakage; an insulated structure, which has aforesaid upper insulated cover 110 and lower insulated cover 120, positive electrode plate 140 is between upper insulated cover 110 and lower insulated cover 120, upper insulated cover 110 has a first workpiece hole 193 and lower insulated cover 120 has a second workpiece hole 195, an upper inner diameter of the second workpiece hole 195 is bigger and a lower inner diameter 121 is smaller than a diameter of the workpiece 100, the first workpiece hole 193 and the second workpiece hole 195 are concentric because of upper insulated cover 110 perpendicular to lower insulated cover 120, workpiece 100 can then be inserted from first workpiece hole 193 to second workpiece hole 195, workpiece 100 on first workpiece hole 193 of upper insulated cover 110 is added a guard 111 for avoiding electric field affection, because an area protected by the guard 111 has no needs to be electrified and polished; workpiece 100 is placed on top of lower inner diameter 121 for workpiece 100 connecting to lower insulated cover 120, thus the area protected by the guard 111 is not electrified and polished by electric field so as to be easily welded. A working piece fixture 150 is around second workpiece hole 195 to fix workpiece 100 in second workpiece hole 195. The working electrode hole 190, first workpiece hole 193 and second workpiece hole 195 are concentric for

negative working electrode 160 going through first workpiece hole 193, second workpiece hole 195 and working electrode hole 190. Positive electrode plate 140, negative electrode plate 130, upper insulated cover 110 and lower insulated cover 120 are parallel each other. Negative working electrode 160 is on an axis of workpiece 100 for offering a function of negative electrode; workpiece 100 plays a role of positive electrode. Depending on a theory of anode half reaction and cathode half reaction, anode ~~loses~~ loses electrons and cathode receives electrons. Thus, the embodiment has an electrolytic reaction after introducing direct current, and then electropolishing process is approached.

Application No. 10/076,308

IN THE DRAWINGS:

Please amend Figure 2 as illustrated in red on the attached photocopy.